

## EAST Search History

## EAST Search History (Prior Art)

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L3	2	JP-09007638-\$.did.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2011/01/10 14:33
L4	2	EP-840386-\$.did.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2011/01/10 14:34
L5	46	(US-20040043294-\$. or US-20030129497-\$. or US-20030180608-\$. or US-20050153208-\$. or US-20050064291-\$. or US-20040166409-\$. or US-20040185346-\$. or US-20030104270-\$. or US-20090130380-\$. or US-20070122700-\$. or US-20060240317-\$. or US-20060207084-\$. or US-20050064292-\$. or US-20040229126-\$. or US-20040029012-\$. or US-20030049532-\$. or US-20020168574-\$. or US-20080193831-\$. or US-20080032192-\$. or US-20020061446-\$. or US-20070059601-\$. or US-20050048369-\$. or US-20030118905-\$. or US-20040033419-\$. did. or (US-5506075-\$. or US-4120772-\$. or US-5395711-\$. or US- 6083644-\$. or US- 6316143-\$. or US- 5686203-\$.).did. or (EP-1231654-\$.).did. or (JP-09245771-\$. or JP-2002260637-\$. or	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2011/01/10 14:47

		JP-2003017040-\$ or JP-2004273443-\$ or JP-2001351614-\$ or JP-2002373653-\$ or JP-2003192327-\$ or JP-55151770-\$ or JP-2002042809-\$ or JP-09007638-\$).did. or (EP-582173-\$ or JP-09245771-\$ or EP-615296-\$ or WO-03085756-\$ or US-6524744-\$).did.				
L6	23	I5 and (cvd pvd (physical chemical) with vapor deposition sputtering)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2011/01/10 14:47
L7	1	JP-3520921-\$).did.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2011/01/10 14:49
L8	2	"20030054249".pn.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2011/01/10 14:50
S59	23	((non near2 aqueous nonaqueous) with electrolyte with secondary with battery) with (((silicon Si) with oxide) SiO "SiO.sub.2" "SiO.sub.x" SiOx SiO2) with (noble with metal Pd Palladium Ag Silver Pt Platinum Au Gold Rh Rhodium Ir Iridium Ru Ruthenium Os Osmium Re Rhenium)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2011/01/10 08:59
S60	0	(anode negative with electrode) with ("SiAgO.sub.1.5" "SiAgO1.5")	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2011/01/10 09:28

S61	0	(anode negative with electrode) with ("SiAgO.sub.2" "SiAgO1.5")	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2011/01/10 09:28
S62	3	((non near2 aqueous nonaqueous) with electrolyte with secondary with battery) with (((silicon Si) with oxide) SiO "SiO.sub.2" "SiO.sub.x" SiOx SiO2) with (noble with metal Pd Palladium Ag Silver Pt Platinum Au Gold Rh Rhodium Ir Iridium Ru Ruthenium Osmium Re Rhenium)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2011/01/10 09:29
S63	684	(anode negative with electrode) with (((silicon Si) with oxide) SiO "SiO.sub.2" "SiO.sub.x" SiOx SiO2) with (noble with metal Pd Palladium Ag Silver Pt Platinum Au Gold Rh Rhodium Ir Iridium Ru Ruthenium Osmium Re Rhenium)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2011/01/10 09:30
S64	167	S63 and (lithium rechargeable secondary nonaqueous electrolyte) with (battery cell)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2011/01/10 09:31
S65	10	"008977".ap.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2011/01/10 10:36
S66	6	(anode negative with electrode) same Ag same SiO same SnO	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2011/01/10 11:35

S67	153	(anode negative with electrode) same Ag same (SiO SnO)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2011/01/10 11:38
S68	884	(anode negative with electrode) with (SiO SnO)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2011/01/10 11:48
S69	445	S68 and (lithium secondary nonaqueous electrolyte rechargeable) with (battery cell)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2011/01/10 11:49
S70	163	S69 and (cvd pvd (physical chemical) with vapor deposition sputtering)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2011/01/10 11:50
S71	2	JP-2002042809-\$.did.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2011/01/10 12:00
S72	2	"20030054249".pn.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2011/01/10 12:01
S73	33	(SiOx "SiO.sub.x") with (anode negative with electrode) same (battery cell).ab.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2011/01/10 12:08
S74	148	(SiOx "SiO.sub.x") with (anode negative with electrode) same (battery cell)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2011/01/10 12:27

S75	100	S74 and (cvd pvd (physical chemical) with vapor deposition sputtering)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2011/01/10 12:27
S76	2	"20040033419".pn.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2011/01/10 12:32

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